## IN THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application.

1. (Currently Amended) A charged-particle beam writer which draws a pattern on a specimen with a charged-particle beam generated from a single particle generator by both of a VSB (variable-shaped beam) strategy and a scan-projection strategy mask-scan strategy, the charged-particle beam writer comprising:

a data creating unit configured to create pattern data representing a state where a first-type figure first figure drawn by the VSB strategy and a second-type figure second figure drawn by the sean-projection strategy mask-scan strategy are arranged on the specimen;

a computing unit configured to calculate, on the basis of the pattern data, the amount of correction for correcting the drawing dimensions of the first-type figure first figure on the specimen and the drawing dimensions of the second-type figure second figure on the specimen; and

a control unit configured to control the dose of beam at each position on the specimen on the basis of the calculated amount of correction.

- 2. (Original) The charged-particle beam writer according to claim 1, wherein the control unit controls the irradiation time of the charged-particle beam for each position on the specimen.
- 3. (Original) The charged-particle beam writer according to claim 1, wherein the particle generator generates as much a charged-particle beam as corresponds to the current supplied to the particle generator, and

the control unit controls the current density of the supplied current for each position on the specimen.

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4. (Original) The charged-particle beam writer according to claim 1, wherein the computing unit calculates the amount of correction on the basis of a pattern density distribution on the specimen.

- 5. (Currently Amended) The charged-particle beam writer according to claim 1, wherein the control unit, when there is a part of the specimen on which the first-type figure first figure and the second-type figure second figure overlap with each other, controls the dose of beam by the VSB strategy and the dose of beam by the sean-projection strategy mask-scan strategy separately at the overlapping part.
- 6. (Currently Amended) The charged-particle beam writer according to claim 1, wherein the control unit, when multiple scanning is done by the scan-projection strategy mask-scan strategy, controls the dose of beam based on the number of multiple scannings at each position on the specimen according to the degree of multiple of the multiple scanning.
- 7. (Original) The charged-particle beam writer according to claim 1, further comprising:
  - a first shaping aperture with a rectangular aperture; and
- a second shaping aperture with a polygonal aperture and a plurality of character apertures, wherein
- a variable-shaped beam is formed by an optical overlap between the rectangular aperture and the polygonal aperture and a character beam is formed by selecting one of the character apertures.
- 8. (Currently Amended) The charged-particle beam writer according to claim 1, wherein a part of the second-type figure second figure is scanned by the scan-projection strategy mask-scan strategy.

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9. (Currently Amended) A charged-particle beam writer which transfers character patterns onto a specimen by a scan-projection strategy mask-scan strategy for scanning the patterns on a mask with a charge-particle beam, the charged-particle beam writer comprising:

a data creating unit configured to create pattern data representing a state where the character patterns are arranged on the specimen;

a computing unit configured to calculate, on the basis of the pattern data, the amount of correction for correcting the drawing dimensions of the character patterns on the specimen; and

a control unit configured to control the dose of beam at each position on the specimen on the basis of the calculated amount of correction.